

Technical Data

PlasmaQuant MS Series ICP-MS





General

Compact, benchtop inductively coupled plasma mass spectrometer (ICP-MS) with full PC control of all instrument settings and compatible accessories. It features a patented 90-degree reflecting ion optics system for superior sensitivity and innovative RF generator design that lowers operating costs by significantly reducing the amount of argon plasma gas required.

Models

PlasmaQuant MS	PlasmaQuant MS Q	PlasmaQuant MS Elite S	PlasmaQuant MS Elite	
For sensitive and robust analysis of high matrix samples	For sensitive and robust high throughput analysis	For efficient analysis of demanding samples	For targeted research applications	
 >500 kcps/ppb ¹¹⁵In BG at 5 amu <0.5 cps 	 800 kcps/ppb ¹¹⁵In BG at 5 amu <0.7 cps 	 1100 kcps/ppb ¹¹⁵In BG at 5 amu <0.7 cps 	 1500 kcps/ppb ¹¹⁵In BG at 5 amu <1 cps 	
	Plasma performance: <Precision: 20 min < 3%	2% CeO ⁺ /Ce ⁺ , <3% Ba ⁺⁺ /Ba ⁺ , 240 min < 4%		

Device option

Option	Description	PQ MS	PQ MS Q	PQ MS Elite S	PQ MS Elite
AMR	Adaptive mass range (AMR) for elements > 230 amu (resolution > 2 amu)	✓	✓	~	~
Nitrox upgrade	Additional gas addition (O2, N2) into the auxiliary gas flow of the plasma to improve plasma performance	✓	✓	✓	✓
Aerosol Dilution Upgrade	Additional gas supply (Ar) to dilute sample aerosol during sample introduction	\checkmark	✓	✓	\checkmark

Hardware

Sample introduction

Peristaltic pump	4 independent channels, pressure adjustable, variable pump speed 0-100 rpm	
Nebulizer	Low flow glass concentric nebulizer – 400 µL/min	
Spray chamber	pray chamber Double pass Scott-type spray chamber, Peltier-cooled with variable temperature room to -1!	
Torch	One-piece low-flow torch with 2.4mm id injector, optional torch with 1.5 and 0.8 mm id injector	



PFA sample introduction kits for low contamination during high purity analyses and for use with hydrofluoric acid samples, semi-demountable torch with sapphire or platinum injector
Organics and volatile organics sample introduction kits including one-piece torch with 1.5 and 0.8 mm id injector and solvent resistant pump tubing

Gas control

Gases 3 plasma gases - plasma, auxiliary and nebulizer gas	
Control Plasma and auxiliary gas – sapphire jets, nebulizer gas – MFC controlled	
Optional gas flows	Sheath gas flow for aerosol dilution, MFC controlled
	Nitrox – additional oxygen or nitrogen added to auxiliary gas, MFC controlled

RF generator

Туре	Solid-state RF generator, virtually center grounded
Specification	27 MHz, 300 V RMS
Power range	300 to 1600 W, in 10 W increments, no plasma shield

Plasma

Control	Automatic ignition and shutdown, user-customizable ignition sequence for different accessories and plasma types
Alignment	Automatic alignment of plasma position (X, Y and Z) for maximum sensitivity and minimum polyatomic interferences
Gas requirements	Argon min. quality 4.6 (99.996%)
Gas consumption	7.5 to 10.5 L/min plasma cooling gas, 1.2-2.0 L/min auxiliary gas – total gas flow 10–12.5 L/min
Cool plasma	Fast switching from hot to cool plasma in one method reduces plasma based spectroscopic interferences for lowest detection limits
Maintenance	Spacious plasma compartment for easy access and simplified routine maintenance

Plasma interface

Туре	ICP-MS interface using Sampler and Skimmer cone
Specification	Sampler cone orifice 1.1 mm, Skimmer cone orifice 0.5 mm
Material	High-performance nickel cones as standard, optional high-performance platinum cones
Cooling	Water-cooled for stability including individual and independent cooling of the cones for faster warm- up, improved stability, and faster cool down
Maintenance	Easy access and removal of sampler and skimmer cone from simple threaded mounts



Interference management

Туре	Integrated Collision Reaction Cell technology (iCRC)
Gas requirements	Hydrogen and helium, min. quality 4.6 (99.996%), Hydrogen generator possible to use for supply
Control	Accurate control by mass flow controllers
Principle	Injects collision and reaction gases into the plasma as it passes through the orifice of the cones
Feature	BOOST technology increases ion transmission in iCRC reaction gas mode by applying a positive voltage to the skimmer cone
Gas switching	Rapid switchover between gas on and gas off, or between different collision and reaction gases

lon optics

Туре	90 degree, reflecting ion optics system	
Lenses	Set of 3 extraction lenses to focus and shape ion beam, segmented ion mirror with 4 lenses (3 user accessible for optimization)	
Focusing of analyte ions	 Patented ion mirror for 3 dimensional focusing of analyte ions by parabolic electrostatic field to aperture of mass analyzer (quadrupole) Photons and neutrals pass through to the vacuum system 	
Optimization	Auto-optimization of all ion optics settings, including ion mirror, based on selected optimization criteria such as signal and interferences	
Maintenance	lon mirror incl. extraction lens 3 is maintenance free, easy access to extraction lens 1 and 2 for cleaning without breaking the vacuum	

HD Quadrupole

RF frequency	3.0 MHz	
Mass range	3–260 amu with 'zero blast' protection	
Resolution	0.5-1.2 amu, adjustable (AMR version: for m/z >230 amu resolution >2amu)	
Scan speed	5115 amu/s	
Dwell time	min. 50 μs	
Mass calibration stability	0.05 amu per day	
Channels per mass	Built-in, on board multi-channel scaler provides up to 40 channels per mass	
Technical specifications	 Precision-machined, stainless steel, round rods manufactured to micrometer tolerances and locked into ceramic mounts for a near-perfect hyperbolic field. 	
	 Stainless steel construction permits determination of Hg without high memory. 	
	 Patented curved entrance rods provide a double off-axis design and low background signals 	
	 Solid-state air-cooled power supply 	
	 All voltages are fully interlocked and under PC control 	



AD Detector

Туре	Discrete dynode electron multiplier (DDEM), all-digital detector, measuring dynodes mounted offer axis for reduced background	
Dynamic range 11 orders linear analytical range, 0.1-10 ¹⁰ cps, all pulse counting mode		
Signal attenuation	Automated or manual 2 step signal attenuation (auto, medium or high) for optimum data acquisition for each individual isotope	
Detector calibration	Regular calibration of attenuation factors (review at any change of detector voltage > 100 V), no frequent analog-to-digital cross calibration necessary	

Vacuum system

	PlasmaQuant MS	PlasmaQuant MS Q	PlasmaQuant MS Elite S	PlasmaQuant MS Elite	
Rotary pump	Leybold SV40, vacuum line 4 m		Edwards XDS 46 vacuum line 4 m		
Turbomolecular pump	2x Pfeiffer HiPace 300 with maintenance-free ceramic bearings				
Isolation valves	Pneumatic vacuum isolation gate between the first and second vacuum stages, gate automatically closes in the event of a power failure				
Stand-by	Automatic standby mode if no plasma or user activity for an extended period of time				
Restart	Automatic restart of vacuum after a power failure				

Data system

Software	ASpect MS with optional 21 CFR Part 11 compliance		
Instrument calibrations	Automated start-up and shut down routines incl. instrument calibrations		
Methods	Pre-configured analytical methods		
Quality control	Range of preconfigured quality controls and actions, option for user defined quality controls		
Reporting / Exporting	G Customized reports and export in prn, csv, txt, lim and cdf		
Requirements	Operating system: PC – Windows 10 (32-Bit or 64-Bit), Windows 7, 8.1 are supported		
	PC: Graphic resolution 1280 x 1024 pixels or higher, mouse / trackball 2 USB 2.0 interface		



Accessories

Accessory	Туре	Features	
Autosampler	Various	Supports various autosampler models e.g. CETAC ASX-560 (XLR-8), other CETAC ASX-models, ESI-DX series, ASPQ 3300	
Discrete sample introduction	Various	Supports different systems e.g. ASXPress Plus, ESI FAST, GE Niagara	
HPLC / IC for speciation	PQ LC compact, PQ LC and PQ IC	Variable LC and IC system in different options, stainless steel or PEEK versions with various upgrades for detection of element species	
	Control	Complete control of workflow, incl. PlasmaQuant MS via Clarity CDS software, including real-time display of time resolved chromatographic signals, calibrations and analysis	
Laser Ablation	TTL trigger communication	Compatible with a range of laser ablation accessories	

Physical data (basic unit)

	PlasmaQuant MS	PlasmaQuant MS Q	PlasmaQuant MS Elite S	PlasmaQuant MS Elite		
Supply voltage	200-240 V AC ±5%	200-240 V AC ±5%	200-240 V AC ±5%	200-240 V AC ±5%		
Frequency	50 / 60 Hz	50 / 60 Hz	50 / 60 Hz	50 / 60 Hz		
Fuse protection	25 A (slow fuse or Type C)	25 A (slow fuse or Type C)	25 A (slow fuse or Type C)	25 A (slow fuse or Type C)		
Power consumption	Typical average power consumption: 2700 W Line current: 18 A max					
Dimensions	660 mm x 589 mm x 1131 mm (W x D x H)					
Weight						
International Protection Marking	IP class 20					
Environmental requirements	 Temperature: +10 °C up to 30 °C (optimum between +15 °C to +25 °C) Relative Humidity: 20-80% at +20 °C Non-condensing atmosphere that is free from corrosive fumes Exhaust extraction: 3.0 m³/min (110 ft³/min) – 4.5 m³/min (160 ft³/min) Maximum altitude: certified 2000 m, please contact us for differing requirements 					

This document is true and correct at the time of publication; the information within is subject to change. Other documents may supersede this document, including technical modifications and corrections.

Content may be used without written permission but with citation of source. Analytik Jena AG